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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/621,277	07/16/2003	Lester L. Begg	81595	3031	
22242 7	590 09/15/2005		EXAMINER		
FITCH EVEN TABIN AND FLANNERY			WYSZOMIERSKI, GEORGE P		
	A SALLE STREET		ART UNIT	PAPER NUMBER	
SUITE 1600 CHICAGO, IL 60603-3406				TATER NOMBER	
CHICAGO, IL	2 00003-3400		1742		
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Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Summan	10/621,277	BEGG, LESTER L.				
Office Action Summary	Examiner	Art Unit				
	George P. Wyszomierski	1742				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).						
Status						
1) Responsive to communication(s) filed on	Responsive to communication(s) filed on .					
3) Since this application is in condition for allowan	Since this application is in condition for allowance except for formal matters, prosecution as to the ments is					
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
<ul> <li>4)  Claim(s) 1-20 is/are pending in the application.</li> <li>4a) Of the above claim(s) is/are withdrawn from consideration.</li> <li>5)  Claim(s) 7-20 is/are allowed.</li> <li>6)  Claim(s) 1-5 is/are rejected.</li> <li>7)  Claim(s) 6 is/are objected to.</li> <li>8)  Claim(s) are subject to restriction and/or election requirement.</li> </ul>						
Application Papers						
<ul> <li>9) The specification is objected to by the Examiner.</li> <li>10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.  Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).</li> <li>11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.</li> </ul>						
Priority under 35 U.S.C. § 119						
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>						
Attachment(s)						
Notice of References Cited (PTO-892)  Notice of Draftsperson's Patent Drawing Review (PTO-948)  Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)  Paper No(s)/Mail Date 10/30/03, 11/03/03.  Notice of Informal Patent Application (PTO-152)  Other:						

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Application/Control Number: 10/621,277 Page 2

Art Unit: 1742

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-5 are rejected under 35 U.S.C. 103(a) as being unpatentable over Soviet Abstract 590370.

The '370 Abstract discloses preparing a monocrystalline bcc metal backing, and depositing monocrystalline tungsten thereon by reaction of tungsten hexafluoride vapor and hydrogen, followed by heating to 1600-1900 degrees C for 30-60 hours. The '370 document does not recite the term chemical vapor deposition of a CVD chamber, does not specify the configuration and composition of the substrate as recited in instant claims 2 and 4, and does not specify the diameter as recited in instant claim 5. These differences are not seen as resulting in a patentable distinction between the prior art and the claimed invention because:

- a) The process as disclosed by SU '370 (reaction of vapors of WF<sub>6</sub> to form W layer) would appear to be equivalent to what is commonly referred to as a chemical vapor deposition process, and it is thus a reasonable assumption that the apparatus used to carry out the prior art process is "suitable for carrying out" a CVD process.
- b) The SU '370 process is forming a material for use in electronics, and it is therefore a reasonable assumption that the prior art process would be amenable to being applied using the thin wire substrate as presently claimed. Further, said substrate

Art Unit: 1742

in the prior art must be one able to withstand the heating temperatures of the prior art, such as one of the refractory metals as recited in claim 4.

c) With respect to claim 5, the heating time of SU '370 is 30-60 hours, and this would appear to be sufficient to form a layer having the presently claimed diameter.

Thus, a prima facie case of obviousness is established between the disclosure of SU '370 and the presently claimed invention.

3. Claim 6 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims. The prior art does not disclose or suggest a process as claimed and which employs chlorides or fluorides of Ta, Re, Nb, or Mo.

Claims 7-20 are allowable over the prior art of record. The prior art does not disclose or suggest forming a tungsten single crystal from the combination of a solid tungsten feedstock and chlorine or fluorine vapors that react with the feedstock, in combination with the two temperature heating steps as required by independent claims 7 and 15.

4. The remainder of the art cited on the attached PTO-892 and 1449 forms is of interest. This art is held to be no more relevant to the claimed invention than the art as applied in the rejections, supra.

Art Unit: 1742

Any inquiry concerning this communication or earlier communications from the examiner should be directed to George Wyszomierski whose telephone number is (571) 272-1252. The examiner can normally be reached on Monday thru Friday from 8:00 a.m. to 4:30 p.m. Eastern time.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Roy King, can be reached on (571) 272-1244. Effective July 15, 2005, all patent application related correspondence transmitted by facsimile must be directed to the new central facsimile number, (571)-273-8300. This new Central FAX Number is the result of relocating the Central FAX server to the Office's Alexandria, Virginia campus.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

**GPW** September 12, 2005